



12/18/2002  
-23-02

PATENT  
Customer No. 22,852  
Attorney Docket No. 04329.2210

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
Katsuhiko HIEDA, et al. ) Group Art Unit: 2811  
Serial No.: 09/469,190 ) Examiner: Hung K. Vu  
Filed: December 21, 1999 )  
For: SEMICONDUCTOR DEVICE AND )  
METHOD FOR )  
MANUFACTURING THE SAME )

Assistant Commissioner for Patents  
Washington, DC 20231

Sir:

**AMENDMENT**

In reply to the Office Action dated September 13, 2001, the period for response extending through January 14, 2002 (January 13, 2002 being a Sunday) by the attached Petition for Extension of Time of one (1) month and requisite fee payment, please amend the application as follows:

**IN THE CLAIMS:**

Please amend claims 10 and 19 as follows:

10. (Amended) A semiconductor device comprising:  
a semiconductor substrate;  
a conductive plug formed on the semiconductor substrate;  
a lower electrode formed in contact with the conductive plug and constituted by a plurality of crystal grains, the crystal grains containing a metallic element;  
a capacitor insulating film formed on a side of the capacitor lower electrode; and